



IPW

1374.43645X00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: A KUROKAWA et al
Application No.: 10/809,525
Filed: March 26, 2004
For: A SEMICONDUCTOR DEVICE AND A METHOD OF
MANUFACTURING THE SAME
Art Unit: 2811
Examiner: C. NGUYEN

AMENDMENT

MS: AMENDMENTS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

August 22, 2005
(Monday)

Sir:

In response to the Office Action dated May 20, 2005, please amend the above-identified application as listed below and as set forth on the following pages:

Amendments to the Title;

Amendments to the Claims; and

Remarks are included following the amendments.

Application No.: 10/809,525
Art Unit: 2811

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AMENDMENTS TO THE TITLE

A- IMPROVED METHOD FOR FORMING PATTERNS ON A SEMICONDUCTOR
DEVICE AND A METHOD OF MANUFACTURING THE SAME USING A LIFT OFF
TECHNIQUE